

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants : Tokumi KOBAYASHI

T. C. Art Unit : 2123

Appl. No. : 10/596,088 (National Stage
of PCT/JP2004/017467)

Examiner : S. S. Rao

I. A. Filed : November 25, 2004

Confirmation No. : 1724

For : CIRCUIT SUBSTRATE PRODUCTION METHOD AND SYSTEM,
SUBSTRATE USED THEREIN, AND CIRCUIT SUBSTRATE USING
THE SAME

RESPONSE UNDER 37 C.F.R. § 1.116

Commissioner for Patents
U.S. Patent and Trademark Office
Customer Service Window, Mail Stop AF
Randolph Building
401 Dulany Street
Alexandria, VA 22314

Sir :

In response to the Final Official Action dated August 17, 2009, setting a three month period for response until November 17, 2009, Applicant respectfully requests reconsideration and withdrawal of the outstanding rejections, as well as an indication of the allowability of all of the claims pending in the present application.

Should an extension of time be necessary to maintain the pendency of the present application, including extensions of time to place the present application in condition for allowance by an Examiner's Amendment, the Commissioner is hereby authorized to charge any additional fee to Deposit Account No. 19-0089.

Remarks/Arguments begin on page 2 of this response.